Electronic Supplementary Material (ESI) for RSC Advances.

"Supporting Information"

NO reduction over Al-embedded MoS_2 monolayer: A first-principles study

Mehdi D. Esrafili * and Safa Heydari

Department of Chemistry, Faculty of Basic Sciences, University of Maragheh, P.O. Box 55136-553, Maragheh, Iran

* Corresponding author. **Phone:** (+98) 4212237955. **Fax:** (+98) 4212276060. **P.O. Box:** 55136-553. **E-mail**: esrafili@maragheh.ac.ir (Mehdi D. Esrafili).

Figure S1. The energy diagram and optimized stationary points for the diffusion of the Al atom on defective MoS_2

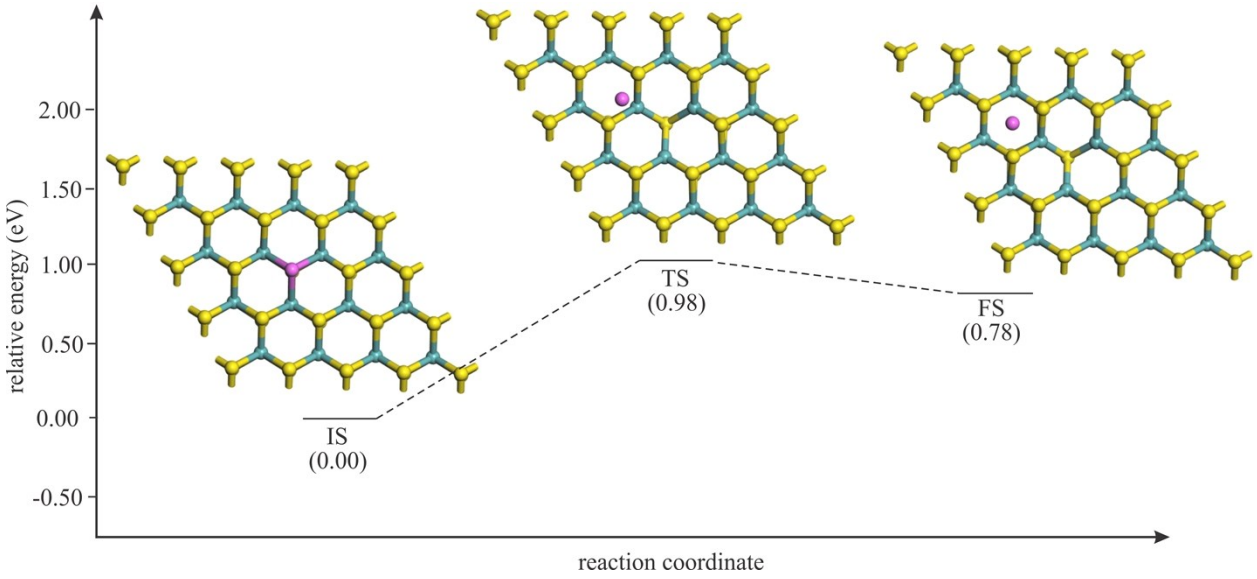

Figure S2. The frontier molecular orbitals of isolated NO and CO molecules